

Product Compliance Declaration

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Contact Information

Name Molex Product Compliance E-Mail Product.Compliance@molex.com

Part Information

Part Number 0022032051 Part Weight 0.333025G

Part Name KK 100 Hdr Flat Vert Tin 5Ckt

Product Composition

Name	Туре	CAS Number	Proportion (% Total)	Mass (Grams)
KK 100 Hdr Flat Vert Tin 5Ckt	Assembly		100	0.333025
.560 x .0261 Sq Brass Bando Pin Tin	Assembly		76.5783	0.255024
.560 x .0261 Sq Brass Bando Pin Unplated	Component		73.5682	0.245
Cartridge Brass 70% Unplated	Material		73.5682	0.245
Copper	Substance	7440-50-8	51.4977	0.1715
Zinc (metal)	Substance	7440-66-6	22.0704	0.0735
Tin Plating	Material		1.3586	0.004524
Tin	Substance	7440-31-5	1.3586	0.004525
Nickel Plating	Material		1.6515	0.0055
Nickel	Substance	7440-02-0	1.6514	0.005499
Further Additives, not to declare	Substance	system	0.0002	6E-07
KK 100 Header Flat 05 Ckt 4030-05	Component		23.4217	0.078
PA66 WHITE	Material		23.4217	0.078

Form Rev - F

Name	Туре	CAS Number	Proportion (% Total)	Mass (Grams)
PA66	Substance		19.9084	0.0663
Flame Retardant, ISO 1043-4 FR(30)	Substance		2.3422	0.0078
Further Additives, not to declare	Substance	system	1.1711	0.0039

ROHS Declaration Information

Regulatory Revision EU 2015/863

Compliance Status Compliant

Contained Substances Exceeding Threshold

None

Exemptions

None

REACH-SVHC Declaration Information

Regulatory Revision D(2021)10043-DC (17 Jan 2022)

Contained Substances Exceeding Threshold

Substance Group	Substance Location	Threshold (PPM)	Concentration (PPM)	Intentionally Added
Benzo(ghi)perylene	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
tricosafluorododecanoic acid	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Octanoic acid, 2,2,3,3,4,4,5,5,6,6,7,7,8,8,8- pentadecafluoro-	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
heptacosafluorotetradecanoic acid	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Dodecamethylcyclohexasiloxane	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Decamethylcyclopentasiloxane	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Benzene-1,2,4-tricarboxylic acid 1,2-anhydride	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Disodium 3,3'-[[1,1'-Biphenyl]-4,4'- Diylbis(Azo)]Bis(4-Aminonaphthalene-1-	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
1,2-Benzenedicarboxylic acid, bis(3-methylbutyl) ester (9CI)	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
methoxyacetic acid	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity

Form Rev - F

Substance Group	Substance Location	Threshold (PPM)	Concentration (PPM)	Intentionally Added
1,2-diethoxyethane	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Dibutyltin-dichloride	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
2-methylimidazole	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
4,4'-methylenedi-o-toluidine	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
1-vinylimidazole	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
1,3-Propanesultone	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
chromium trioxide	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
C.I. Direct Black 38	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
henicosafluoroundecanoic acid	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Ammonium-pentadecafluorooctanoate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
sodium peroxometaborate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Disodium-octaborate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
1,7,7-trimethyl-3- (phenylmethylene)bicyclo[2.2.1]heptan-2-one	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
2-ethylhexyl 10-ethyl-4,4-dioctyl-7-oxo-8-oxa-3,5-dithia-4-stannatetradecanoate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Acetamide, N-methyl-	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
p-(1,1-dimethylpropyl)phenol	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Dicyclohexyl-phthalate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Dihexyl-phthalate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Phenanthrene	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Dinoseb	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
butyl 4-hydroxybenzoate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
o-toluidine	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
4-methyl-m-phenylenediamine	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Imidazolidine-2-thione	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
4-o-tolylazo-o-toluidine	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
4-tert-butylphenol	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
nitrobenzene	.560 x .0261 Sq Brass Bando Pin	1,000	3,000	Impurity
1-bromopropane	Unplated .560 x .0261 Sq Brass Bando Pin	1,000	3,000	Impurity
Ethylenediamine	Unplated .560 x .0261 Sq Brass Bando Pin	1,000	3,000	Impurity
	Unplated			

Substance Group	Substance Location	Threshold (PPM)	Concentration (PPM)	Intentionally Added
furan	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
2-Methoxyethyl acetate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Glutaral	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
6,6'-di-tert-butyl-2,2'-methylenedi-p-cresol	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
6-methoxy-m-toluidine	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
C,C'-azodi(formamide)	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
1,4-dioxane	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Dipentyl phthalate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
bis(2-(2-methoxyethoxy)ethyl) ether	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
2-(2H-Benzotriazol-2-yl)-4,6-ditertpentylphenol	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
2,3,3,3-tetrafluoro-2- (heptafluoropropoxy)propionic acid, its salts and	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Tris(4-nonylphenyl, branched and linear) phosphite (TNPP) with ≥ 0.1% w/w of 4-	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
2,2-bis(bromomethyl)propane-1,3-diol (BMP); 2,2-dimethylpropan-1-ol, tribromo derivative/3-	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
2-(4-tert-butylbenzyl)propionaldehyde and its individual stereoisomers	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Medium-chain chlorinated paraffins (MCCP)	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
orthoboric acid, sodium salt	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Phenol, alkylation products (mainly in para position) with C12-rich branched alkyl chains	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Perfluorobutane sulfonic acid (PFBS) and its salts	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Fluoranthene	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Pyrene	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Benz[a]anthracene	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Cadmium nitrate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Chrysene	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Dodecachloropentacyclo[12.2.1.16,9.02,13.05,1 0]octadeca-7,15-diene ("Dechlorane Plus" TM)	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Dioctyltin dilaurate, stannane, dioctyl-, bis(coco acyloxy) derivs., and any other stannane,	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Perfluorononan-1-oic acid (2,2,3,3,4,4,5,5,6,6,7,7,8,8,9,9,9-	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
4-(1,1,3,3-tetramethylbutyl)phenol, ethoxylated	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
hexahydro-2-benzofuran-1,3-dione	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Methylhexahydrophthalic anhydride	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity

Substance Group	Substance Location	Threshold (PPM)	Concentration (PPM)	Intentionally Added
Sodium perborate; perboric acid, sodium salt	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Cadmium sulphate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
reaction mass of 2-ethylhexyl 10-ethyl-4,4- dioctyl-7-oxo-8-oxa-3,5-dithia-4-	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
5-sec-butyl-2-(2,4-dimethylcyclohex-3-en-1-yl)-5-methyl-1,3-dioxane [1], 5-sec-butyl-2-(4,6-	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Perfluorohexane-1-sulphonic acid and its salts	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Terphenyl, hydrogenated	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
1,2-Benzenedicarboxylic acid, dihexyl ester, branched and linear	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
diisohexyl phthalate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
pentacosafluorotridecanoic acid	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
1,2-Benzenedicarboxylic acid, dipentyl ester, branched and linear	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
2-Methyl-1-(4-methylthiophenyl)-2- morpholinopropan-1-one	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
4,4-isobutylethylidenediphenol	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
2-benzyl-2-dimethylamino-4- morpholinobutyrophenone	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
3-ethyl-2-methyl-2-(3-methylbutyl)-1,3- oxazolidine	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
n-pentyl-isopentylphthalate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
S-(tricyclo(5.2.1.02,6)deca-3-en-8(or 9)-yl O- (isopropyl or isobutyl or 2-ethylhexyl) O-	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
1,3-BENZENEDIOL, TRINITRO-, LEAD SALT	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Hydrazine	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Disodium tetraborate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Boric acid	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
4,4'-Oxydianiline and its salts	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Aluminosilicate Refractory Ceramic Fibres	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Zirconia Aluminosilicate Refractory Ceramic Fibres	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Acids generated from chromium trioxide and their oligomers	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
4-Nonylphenol, branched and linear [substances with a linear and/or branched alkyl chain with a	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
4-(1,1,3,3-tetramethylbutyl)phenol, ethoxylated [covering well-defined substances and UVCB	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
4-Nonylphenol, branched and linear, ethoxylated [Substances with a linear and/or branched alkyl	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
4-Heptylphenol, branched and linear	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Nonadecafluorodecanoic acid (PFDA) and its sodium and ammonium salts	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity

Substance Group	Substance Location	Threshold (PPM)	Concentration (PPM)	Intentionally Added
Carbonic acid, cobalt(2+) salt (1:1)	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Acetic acid, cobalt(2+) salt	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Cobalt-dinitrate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Cobalt sulphate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
2-Ethoxyethyl acetate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Strontium-chromate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
1,2-Benzenedicarboxylic acid, di-C7-11- branched and linear alkyl esters	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
1-Methyl-2-pyrrolidone	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
1,2,3-Trichloropropane	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
1,2-Benzenedicarboxylic acid, di-C6-8-branched alkyl esters, C7-rich	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Calcium-arsenate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
bis(2-methoxyethyl) ether	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Potassium hydroxyoctaoxodizincatedichromate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Lead-dipicrate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
N,N-dimethylacetamide (DMAc, DMA)	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Arsenic-acid	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
2-methoxyaniline	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Trilead-diarsenate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
1,2-dichloroethane	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Formaldehyde, polymer with benzenamine	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
1,2-Benzenedicarboxylic acid, bis(2-methoxyethyl) ester	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
phenolphthalein	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Dichromium tris(chromate)	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
2,2'-dichloro-4,4'-methylenedianiline	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Arsenic acid (H3AsO4), triethyl ester	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
4,4'-diaminodiphenylmethane	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Dibutylphthalate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Di-(2-ethylhexyl)phthalat	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Arsenic acid (H3AsO4), lead(2+) salt (1:1)	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity

Substance Group	Substance Location	Threshold (PPM)	Concentration (PPM)	Intentionally Added
2,4-Dinitrotoluene	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Anthracene oil; Anthracene oil	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Anthracene oil, anthracene paste; Anthracene Oil Fraction	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Anthracene oil, anthracene paste, anthracene fraction; Anthracene Oil Fraction	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Anthracene oil, anthracene paste, distn. lights; Anthracene Oil Fraction	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Anthracene oil, anthracene-low; Anthracene Oil Fraction	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Diisobutyl-phthalate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Lead chromate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Lead chromate molybdate sulfate red	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Lead sulfochromate yellow	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Pitch, coal tar, high-temp.	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Tris(2-chloroethyl) phosphate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Ammonium-dichromate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Potassium-chromate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Potassium-dichromate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Sodium-chromate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Boric acid, disodium salt, hydrate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Trichloroethylene	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
2-Ethoxyethanol	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
formamide	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Cadmium-chloride	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Silicic acid, lead salt	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Lead oxide sulfate (Pb2O(SO4))	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Lead-titanium-trioxide	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Pentalead-tetraoxide-sulphate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Trilead-dioxide-phosphonate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Tetralead-trioxide-sulphate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Dioxobis(stearato)trilead	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Lead titanium zirconium oxide	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
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Substance Group	Substance Location	Threshold (PPM)	Concentration (PPM)	Intentionally Added
Borate(1-), tetrafluoro-, lead (2+)	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Cyanamide, lead(2+) salt (1:1)	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Cadmium Hydroxide	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Acetic Acid, Lead Salt, Basic	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Sulfurous Acid, Lead Salt, Dibasic	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Silicic acid (H2Si2O5), barium salt (1:1), lead-doped	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
[Phthalato(2-)]dioxotrilead	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Fatty Acids, C16-18, Lead Salts	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Lead(II) methanesulfonate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
1,3,5-tris-[(2S and 2R)-2,3-epoxypropyl]-1,3,5-triazine-2,4,6-(1H,3H,5H)-trione	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
4-aminoazobenzene	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
diethyl sulphate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
propylene oxide	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
4,4'-(1-Methylpropylidene)bisphenol	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
dimethyl sulphate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Tetraethyllead	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
4,4'-bis(dimethylamino)benzophenone	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
N,N,N',N'-tetramethyl-4,4'-methylendianiline	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
1,2-Dimethoxyethane	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
1,2-bis(2-methoxyethoxy)ethane	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Lead di(acetate)	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Cadmium-carbonate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
[4-[4,4'-bis(dimethylamino) benzhydrylidene]cyclohexa-2,5-dien-1-	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
4,4'-bis(dimethylamino)-4"-(methylamino)trityl alcohol [with ≥ 0.1% of Michler's ketone (EC No.	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Decabromodiphenylether	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Diboron-trioxide	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Cadmium-oxide	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Cadmium-sulphide	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Lead(II,IV)-oxide	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity

Substance Group	Substance Location	Threshold (PPM)	Concentration (PPM)	Intentionally Added
Trilead bis(carbonate) dihydroxide	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Lead Oxide	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
1,3,5-tris(oxiranylmethyl)-1,3,5- triazine-2,4,6(1H,3H,5H)-trione	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
[4-[[4-Anilino-1-naphthyl][4- (dimethylamino)phenyl]methylene]cyclohe	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
α,α-Bis[4-(dimethylamino)phenyl]-4 (phenylamino)naphthalene-1-methanol [with ≥	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Lead	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	2,000	Impurity
Cadmium	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Cadmium-fluoride	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
pyrochlore, antimony lead yellow	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity
Lead-dinitrate	.560 x .0261 Sq Brass Bando Pin Unplated	1,000	3,000	Impurity

GADSL Declaration Information

Regulatory Revision GADSL imported from IMDS

Contained Substances Exceeding Threshold

Substance Group	Substance Location	Threshold (PPM)	Concentration (PPM)	Intentionally Added
copper	Cartridge Brass 70% (CA260)	*Note	700,000	Yes
nickel powder [particle diameter < 1 mm]	Ep-Ni	*Note	997,500	Yes
Lead	e-plate Sn (electrodeposited Tin Coatings, bright and matt)	*Note	500	Yes
Lead	Cartridge Brass 70% (CA260)	*Note	350	Yes

^{*}Note: For GADSL substance declarable/prohibited threshold values, please reference http://www.gadsl.org/

Exemptions

Part Name	Exemption
Ep-Ni	33 Other application (Surface not routinely touched or nickel release rate < 0.5µg/cm2/week)
e-plate Sn (electrodeposited Tin Coatings, bright and matt)	44 Concentration within acceptable GADSL limits
Cartridge Brass 70% (CA260)	44 Concentration within acceptable GADSL limits

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HFLH Declaration Information

Regulatory Revision IEC 61249-2-21

Contained Substances Exceeding Threshold

None

China ROHS Declaration Information

Part Number 0022032051 Part Name KK 100 Hdr Flat Vert Tin 5Ckt						
Part Information		Haz	zardous S	Substance	es	
Components	Lead	Mercury	Cadmium	Hex. Chromium	PBB	PBDE
KK 100 Hdr Flat Vert Tin 5Ckt	0	0	0	0	0	0
.560 x .0261 Sq Brass Bando Pin Tin	0	0	0	0	0	0
.560 x .0261 Sq Brass Bando Pin Unplated	0	0	0	0	0	0
KK 100 Header Flat 05 Ckt 4030-05	0	0	0	0	0	0

Additional Information

Annex XVII to REACH (76/769/EEC)	Compliant
Regulation (EU) 2019/1021 (POP)	Compliant

Process Information

Component Plating / Surface Finish	MSn-RNi
Termination Base Alloy	Brass
Solder Alloy	N/A
Process Capability	WAVE
Maximum Exposure Time (seconds)	005
Maximum Process Temperature (C)	235

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Maximum Cycles at Reflow Temperature	001
J-STD-020 Moisture Sensitivity Level	N/A

Mar 2, 2022